

## THE SCOPE OF THE NATIONAL EPITAXY FACILITY (SHEFFIELD) QUALITY MANAGEMENT SYSTEM

Design, research and production/growth of compound semiconductor wafers using MBE and MOVPE reactors at the University of Sheffield. This includes the design and fabrication of semiconductor devices in support of epitaxial growth, heterogeneous integration of devices and materials, the testing and characterization of products, and collaboration with customers through pump priming to increase the Facility's capability to meet future requirements.

This quality management system is implemented at the request of the Engineering Physical Sciences Research Council (EPSRC), to ensure the National Epitaxy Facility continues to improve its service in supplying the UK universities research community with high quality semiconductor materials.

Date: 14<sup>th</sup> September 2023

Issue 1.3

Next review date: September 2024

Owner: J Heffernan

### **The Facility Location:**

#### **Centre for Nanoscience and Technology.**

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